



312.104331R00

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicants: K. HILL, et al.  
Application No.: 09/342,707  
Filed: June 29, 1999  
For: METHOD OF FABRICATING BRASS GRATINGS USING  
A SILICA PHASE GRATING MASK AND MASK USED  
BY SAME  
Art Unit: 2874  
Examiner: B. Healy

**RESPONSE TO EX PARTE QUAYLE**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

RECEIVED  
OCT - 9 - 2003  
TECHNOLOGY CENTER 2800  
October 9, 2003

Sir:

In response to the Ex parte Quayle Office Action mailed July 1, 2003, the period for response for which extension is requested by the attached Petition for Extension of Time, Applicants respectfully request reconsideration for the reasons set forth below.

Appreciation is expressed to the Examiner for the allowance of claims 1-29 and 43-54 in this case.

In the Office Action, it is noted that the original letters patent, or a statement of loss or inaccessibility thereof, must be received before the reissue application can be allowed. Accordingly, Applicants are enclosing herewith the original letters patent for USP 5,367,588 in order to complete all requirements for this reissue application. Accordingly, allowance of this application is respectfully requested.